	Application No.	Applicant(s)
Notice of Allowability	10/621,046	GRIGOROPOULOS ET AL.
	Examiner	Art Unit
	Chandra Chaudhari	2891
The MAILING DATE of this communication appears All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this ap or other appropriate communication IGHTS. This application is subject to	plication. If not included nwill be mailed in due course. THIS
1. A This communication is responsive to <u>amendment filed Jan</u>	uary 6, 2006.	
2. ⊠ The allowed claim(s) is/are <u>1-25 and 35-39</u> .	•	·
3.	e been received. e been received in Application No cuments have been received in this of this communication to file a reply MENT of this application. iitted. Note the attached EXAMINER es reason(s) why the oath or declara st be submitted. son's Patent Drawing Review (PTO- s Amendment / Comment or in the C .84(c)) should be written on the drawing.	national stage application from the complying with the requirements 'S AMENDMENT or NOTICE OF stion is deficient. 948) attached Office action of the back) of
each sheet. Replacement sheet(s) should be labeled as such in to 6. DEPOSIT OF and/or INFORMATION about the depo	he header according to 37 CFR 1.121(sit of BIOLOGICAL MATERIAL r	d). must be submitted. Note the
Attachment(s) 1. Notice of References Cited (PTO-892) 2. Notice of Draftperson's Patent Drawing Review (PTO-948) 3. Information Disclosure Statements (PTO-1449 or PTO/SB/O Paper No./Mail Date	5. ☐ Notice of Informal P 6. ☐ Interview Summary Paper No./Mail Dat 08), 7. ⊠ Examiner's Amendr	ratent Application (PTO-152) (PTO-413), te
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An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with George Wolken on March 3, 2006.

The application has been amended as follows:

Claims 30-34 have already been cancelled in the amendment/response filed April 18, 2005, and claims 26-29 have been cancelled in the amendment filed on January 6, 2006.

Delete claim 38 from the amendment filed January 6, 2006, and insert new claim 38 as:

- -- A method for making a capacitor comprising:
- a) depositing a first electrically conductive structure on an insulating substrate comprising the steps of;
 - a1) depositing drops of a first suspension onto said insulating substrate,

wherein said first suspension comprises nanoparticles of a material suspended in a liquid, and,

wherein said insulating substrate lacks recesses in the region where said drops are deposited onto said insulating substrate; and,

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- a2) exposing said nanoparticles on said insulating substrate to at least one localized spot of laser light such that said nanoparticles are at least partially melted by said at least one localized spot of laser light; and,
- a3) solidifying said at least partially melted nanoparticles, forming thereby said first electrically conductive structure on said insulating substrate; and,
- b) depositing a dielectric structure on said first electrically conductive structure, comprising the steps of;
- b1) depositing drops of a polymerizable liquid on said first electrically conductive structure; and,
- b2) polymerizing said drops of said polymerizable liquid, forming thereby a dielectric structure on said first electrically conductive structure; and,
- c) depositing a second electrically conductive structure on said dielectric structure, comprising the steps of;
- c1) depositing drops of a second suspension onto said dielectric structure,
 wherein said second suspension comprises nanoparticles of a material suspended in a
 liquid, and,
- c2) exposing said nanoparticles on said dielectric structure to at least one localized spot of laser light such that said nanoparticles are at least partially melted by said at least one localized spot of laser light; and,
- c3) solidifying said at least partially melted nanoparticles, forming thereby said second electrically conductive structure on said dielectric structure, such that said first electrically conductive structure and said second electrically conductive structure surround said dielectric structure forming thereby a capacitor.--

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Delete claim 39 from the amendment filed January 6, 2006, and insert new claim 39 as:

--A method for crossing a first electrical conductor and a second electrical conductor on an insulating substrate while maintaining electrical isolation between said first and second electrical conductors, comprising:

- a) depositing a first electrically conductive structure on an insulating substrate comprising the steps of;
 - a1) depositing drops of a first suspension onto said insulating substrate,

wherein said first suspension comprises nanoparticles of a material suspended in a liquid; and, wherein said insulating substrate lacks recesses in the region where said drops are deposited onto said insulating substrate; and,

- a2) exposing said nanoparticles on said insulating substrate to at least one localized spot of laser light such that said nanoparticles are at least partially melted by said at least one localized spot of laser light; and,
- a3) solidifying said at least partially melted nanoparticles, forming thereby said first electrically conductive structure on said insulating substrate; and,
- b) depositing an insulating structure on said first electrically conductive structure, comprising the steps of;
- b1) depositing drops of a polymerizable liquid on said first electrically conductive structure; and,

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b2) polymerizing said drops of said polymerizable liquid, forming thereby an insulating structure on said first electrically conductive structure; and,

- c) depositing a second electrically conductive structure on said insulating structure, comprising the steps of;
- c1) depositing drops of a second suspension onto said insulating structure,
 wherein said second suspension comprises nanoparticles of a material suspended in a
 liquid, and,
- c2) exposing said nanoparticles on said insulating structure to at least one localized spot of laser light such that said nanoparticles are at least partially melted by said at least one localized spot of laser light; and,
- c3) solidifying said at least partially melted nanoparticles, forming thereby said second electrically conductive structure on said insulating structure; such that said first electrically conductive structure and said second electrically conductive structure are separated by said insulating structure and maintain electrical isolation thereby.--

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Any inquiry concerning this communication or earlier communications from the examiner

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should be directed to Chandra Chaudhari whose telephone number is 571-272-1688. The examiner

can normally be reached on Mon - Fri (9:00-5:30).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor,

Bill Baumeister can be reached on 571-272-1722. The fax phone number for the organization

where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about the PAIR system,

see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system,

contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Chandra Chaudhari Primary Examiner Art Unit 2891

Chandra Chaudhari March 13, 2006